



Solar_{PV} Energy

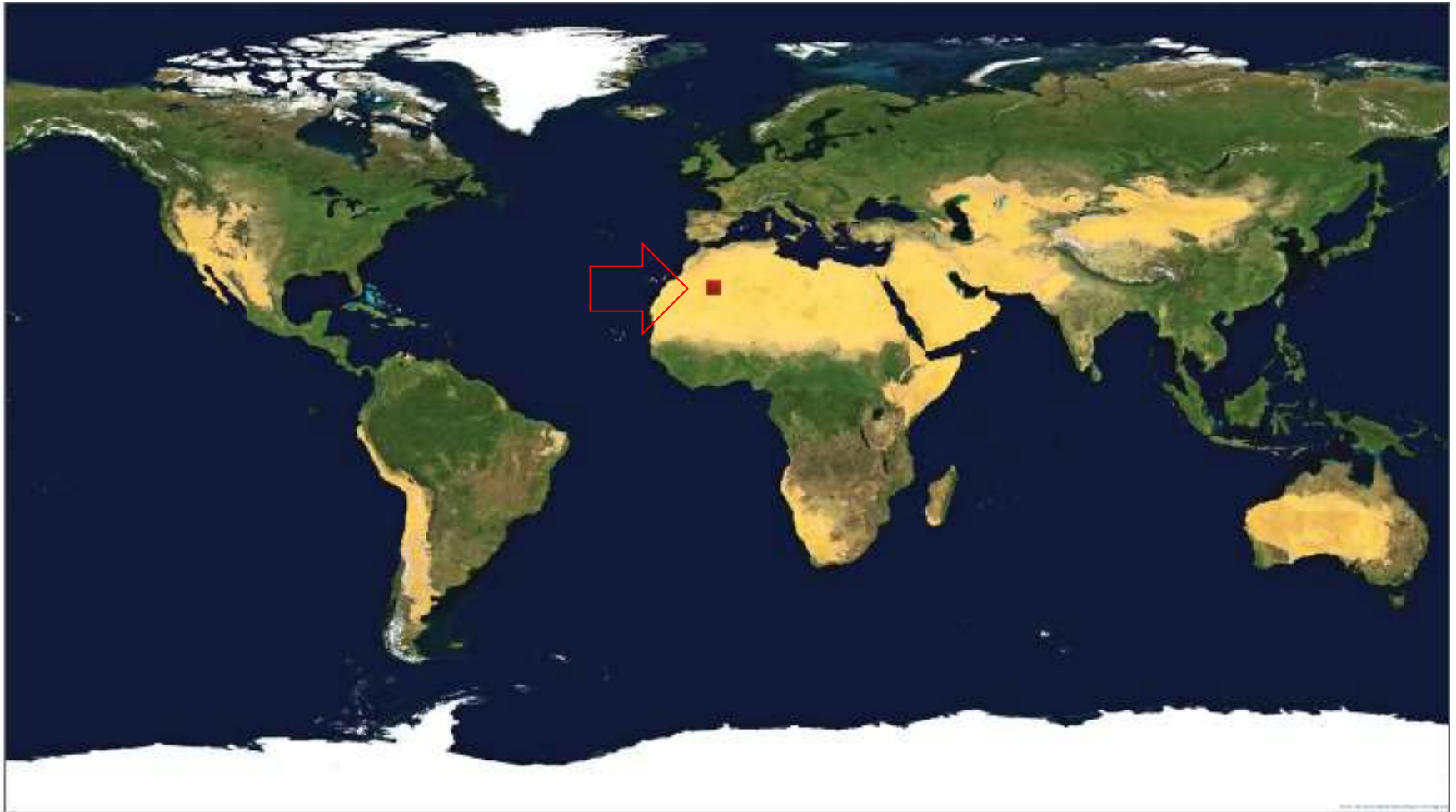
“Solar Park” 31 MW farm in Les Mees/France (2011)
6 solar PV plants (Eco Delta Développement, EDD)

112,000 solar modules on 70 hectares.
Inverters: low- and medium-voltage components/ DC-AC
transformers. Siemens responsible for the civil works and
substructure, performs maintenance on power plants.

Agenda: RenE Solar PV Energy Conversion

- Intro: Solar insolation, power density, solar emission spectrum
- Utility size(solar farms) & residential PV arrays
- Silicon solar photo-voltaic (PV) technology
 - Semiconductor band structure, gap, junctions
 - Charge carriers in n-type and p-type semiconductors
 - Photocell operation, efficiency
 - Silicon wafer, cell manufacture
 - Materials and emissions in construction
- US and World installations and performance, system cost and incentives
- Solar power strategic issues

Partially Sunny World



Demand 20 TW worldwide → harvest sunlight (**total insolation 10^5 TW**). **Methods:**
→ **Direct** (photon → e^- , h exciton) conversion to el. : photo-voltaic (PV), amorphous Si, single crystal Si, thin-film, organic solar cells
→ **Indirect** (thermal) conversion to electricity: concentrated solar power plant (CSP)

Free Power: Solar Radiation

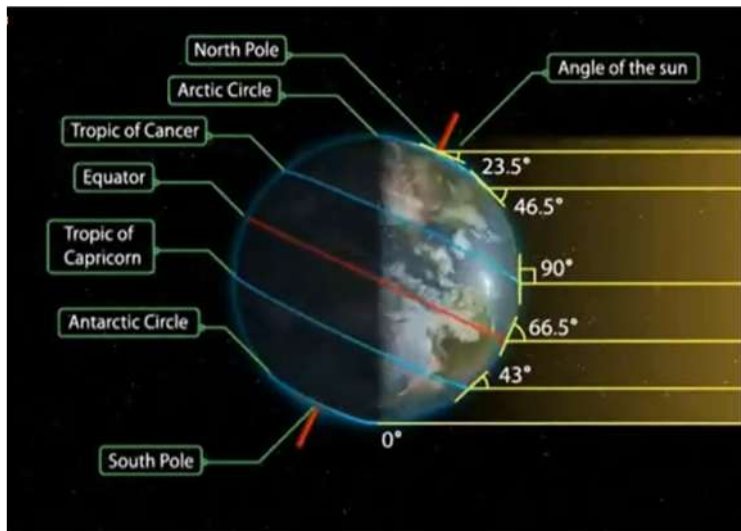
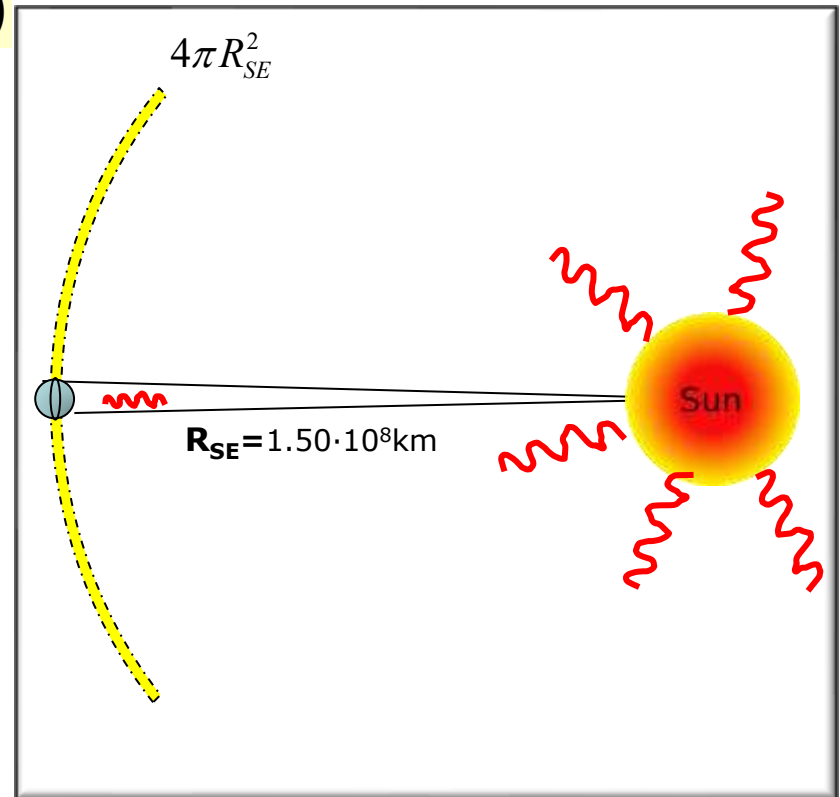
Stefan-Boltzmann Law $S = \sigma \cdot T_S^4$ (W/area)

Solar direct S = mean power density

$$A_{R_{SE}} = \pi R_E^2 = \frac{1}{4} A_E; A_E = 5.1 \times 10^8 \text{ km}^2$$

$$S \cdot A_{R_{SE}} = \sigma \cdot T_S^4 \cdot (4\pi R_S^2) \cdot \left(\frac{A_{R_{SE}}}{4\pi R_{SE}^2} \right)$$

$$S = \sigma \cdot T_S^4 \cdot \left(\frac{R_S^2}{R_{SE}^2} \right) \approx 1.370 \text{ kW/m}^2$$



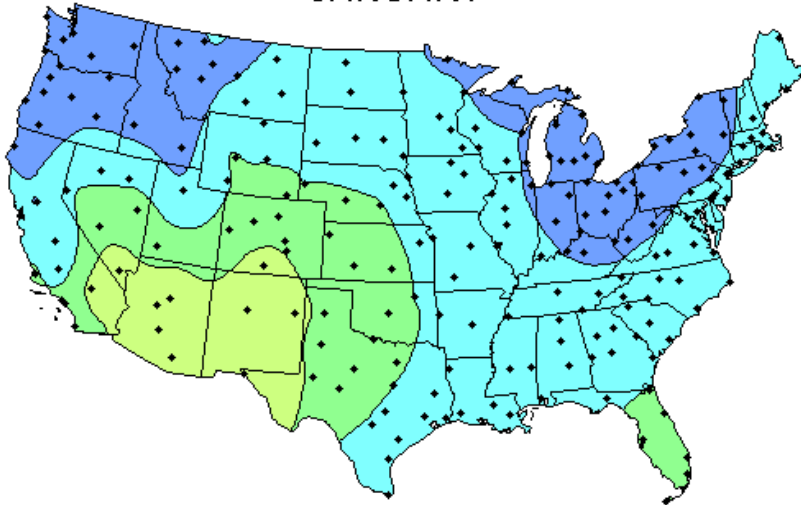
Solar radiation incidence during summer on northern hemisphere

Angle of incidence $\neq 90^\circ$ reduced power

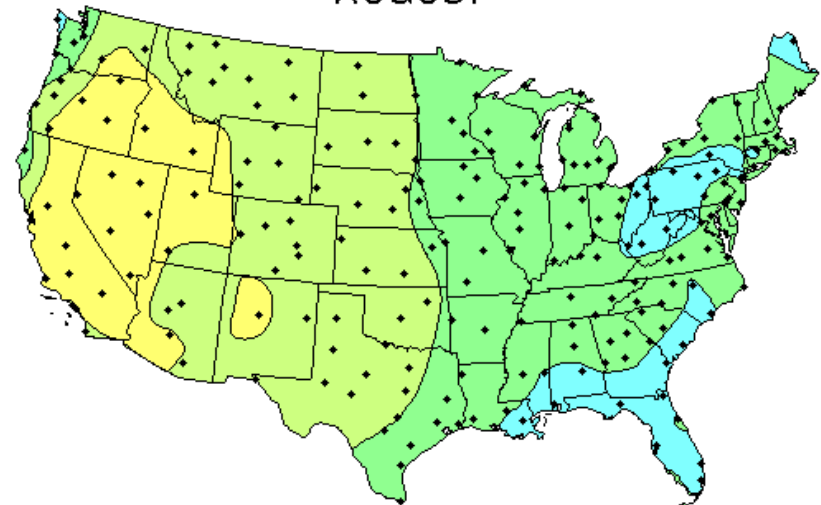
$$\text{ROC@ } 47^\circ \text{ latitude} \rightarrow S_{\text{eff}}(\theta) < S$$

Average Daily Insolation

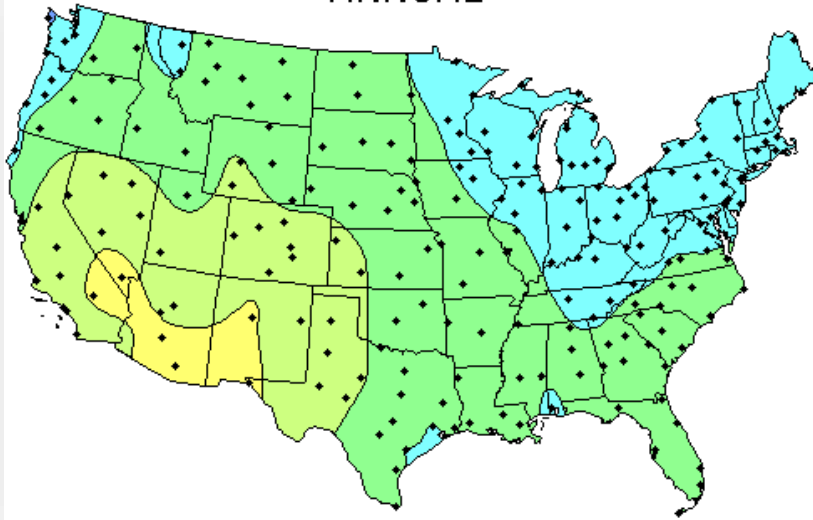
JANUARY



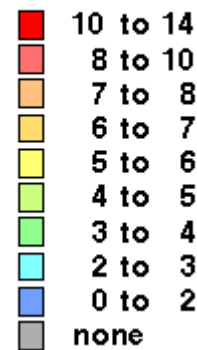
AUGUST



ANNUAL



kWh/m²/day



August in NY:
(2-4)kWh/d·m²

Compare to

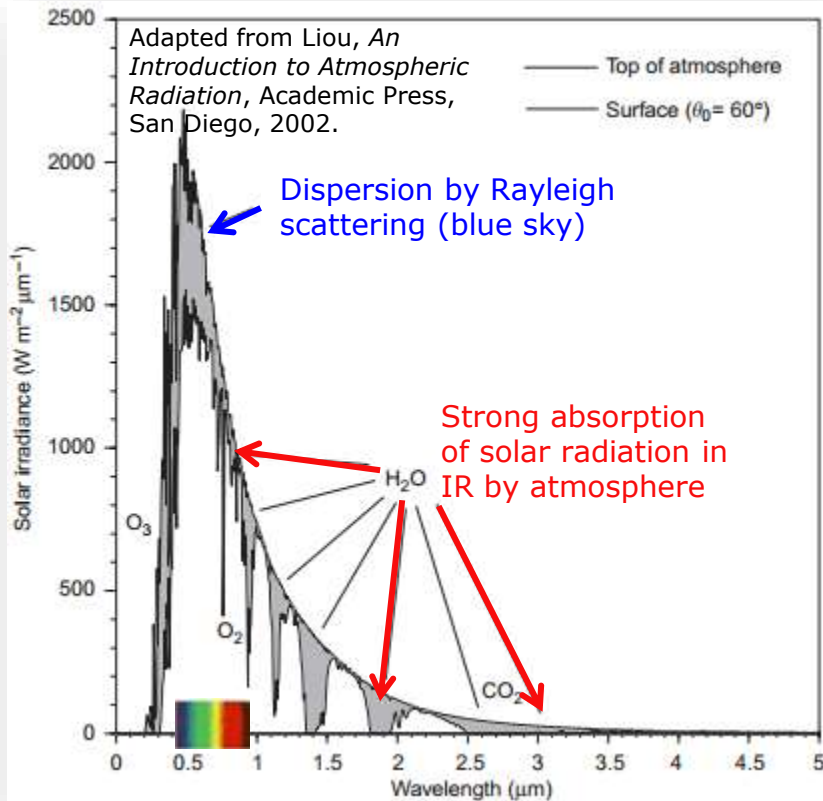
$$I = S \cdot \frac{12h}{d} \approx 17 \text{ kWh}/(\text{d} \cdot \text{m}^2)$$

Energy use US-NE:
(20-30) kWh/d·pers,

twice that in US-SW

http://rredc.nrel.gov/solar/old_data/nsrdb/1961-1990/redbook/atlas/

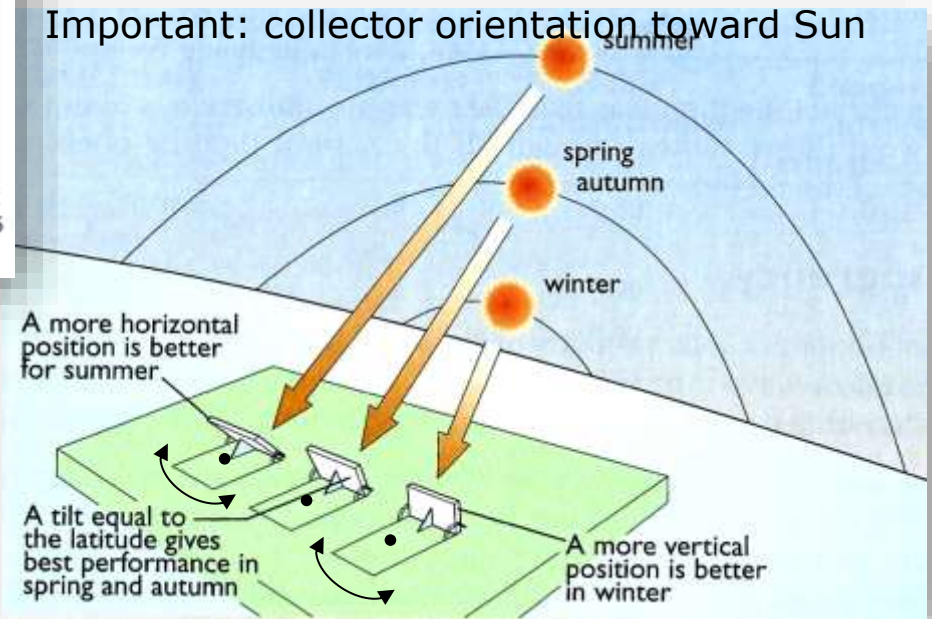
Capturing Sun Rays on Surface



Intense solar radiation available at wave lengths from the UV, over visible to IR.
Spectral gaps due to atmospheric absorption.

Utilization for electricity production:
Photo-voltaic (PV) \rightarrow direct electrical conversion. Concentrated Solar (CSP) = thermal conversion

Important: collector orientation toward Sun

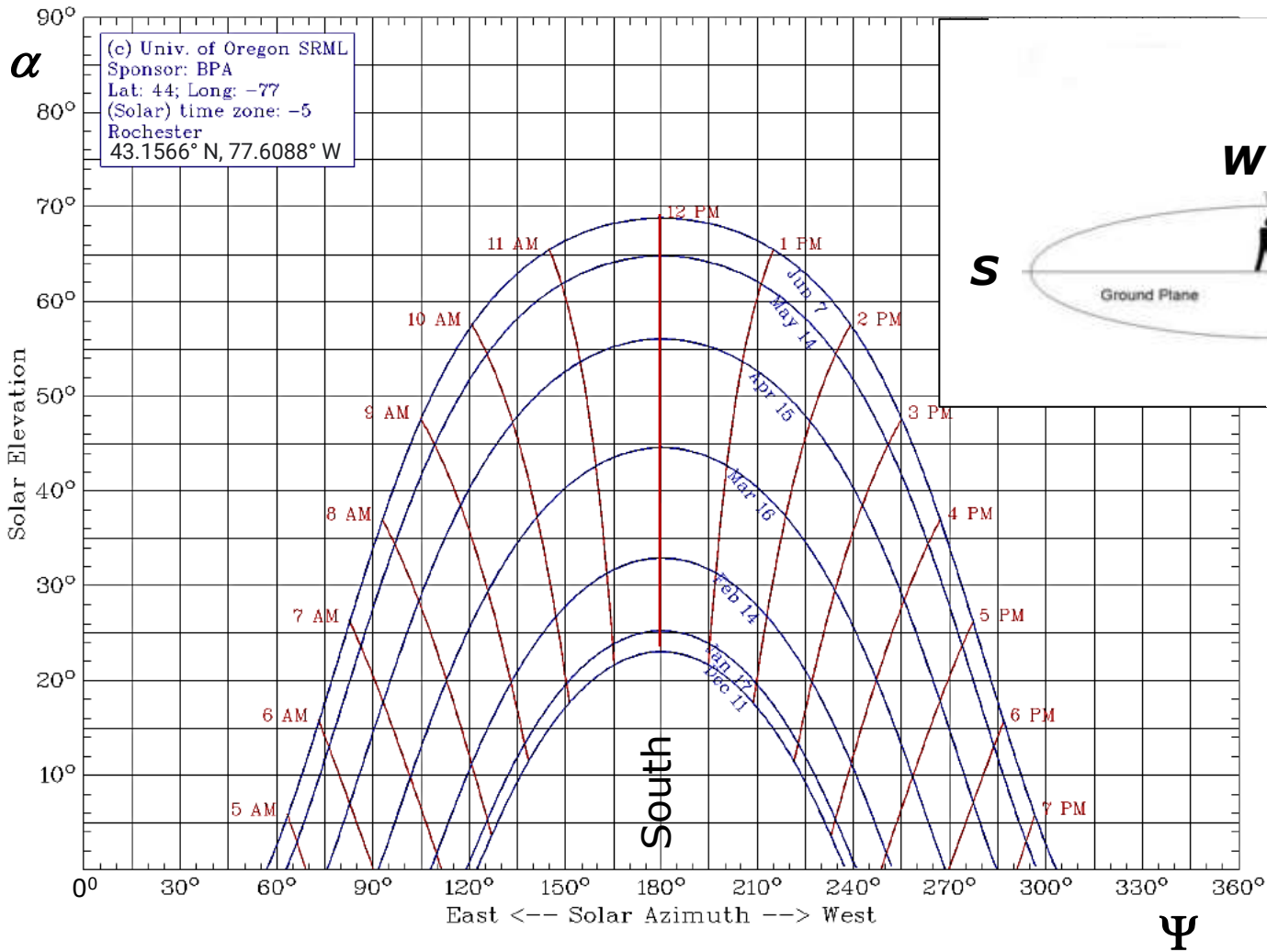


Apparent orbits of Sun on sky require different tilt of sensors for best efficiency ϵ .
Can vary by $\Delta\epsilon = \pm 15\%$.

Concentrated Solar Power = CSP
"Receivers" collect and focus sunlight,
Tracking for (θ, ϕ) best efficiency.

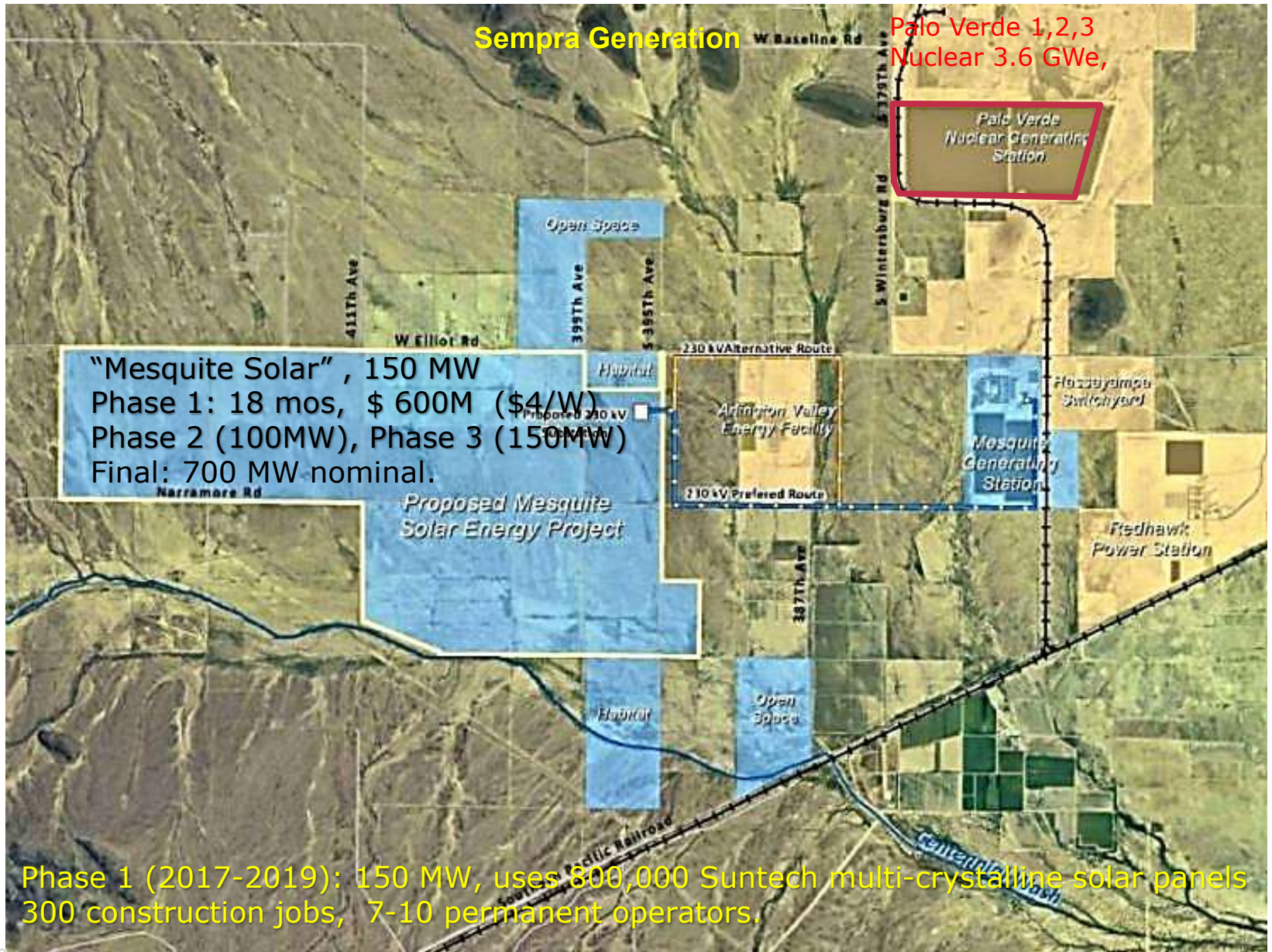
Adapted from G. Boyle et al., Renewable energy, OUP

Rochester Solar Elevation α (app.) vs. Azimuth

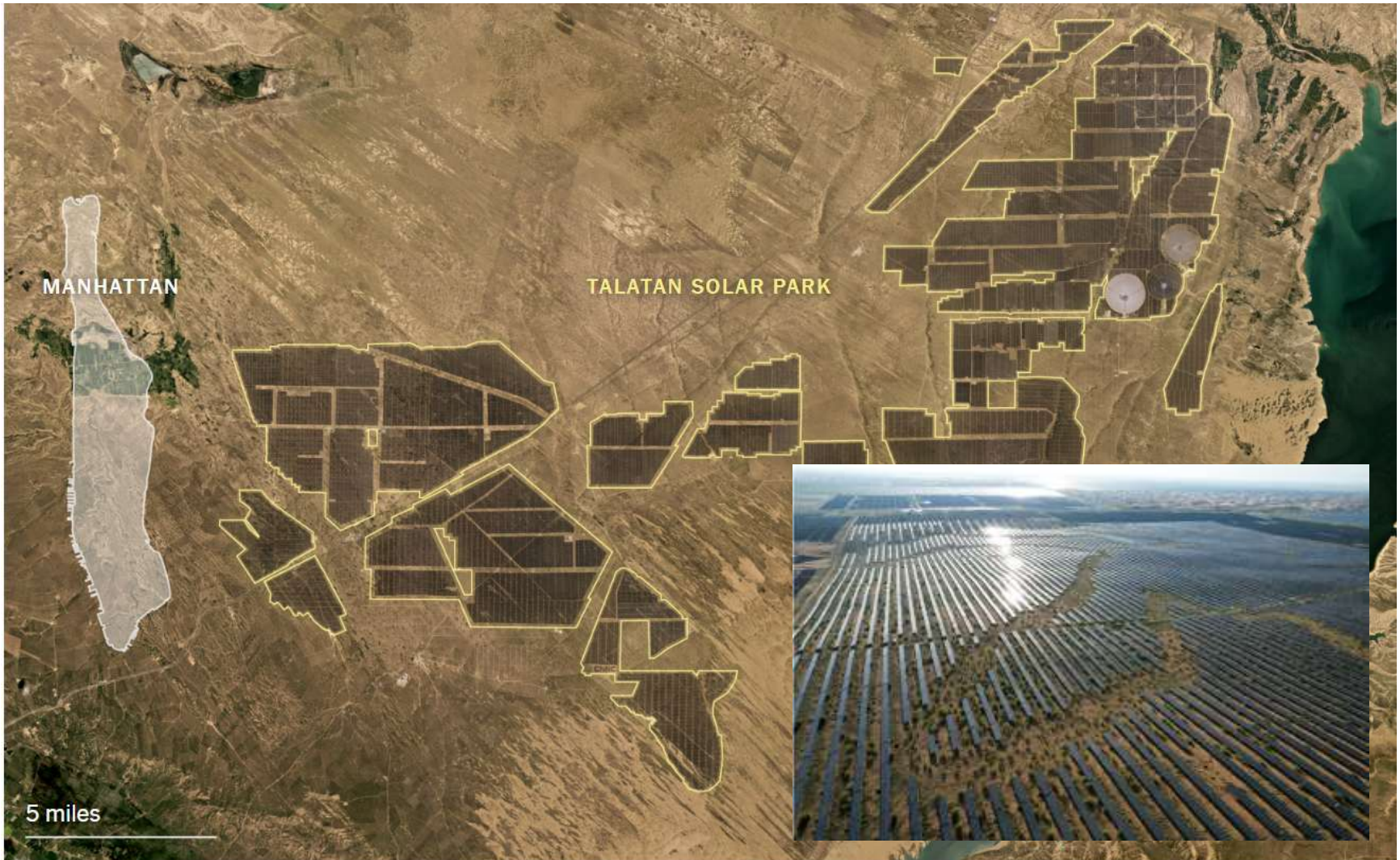


ESTS 3-6-2 PV Solar Power 7

Big US PV Projects: Mesquite Solar

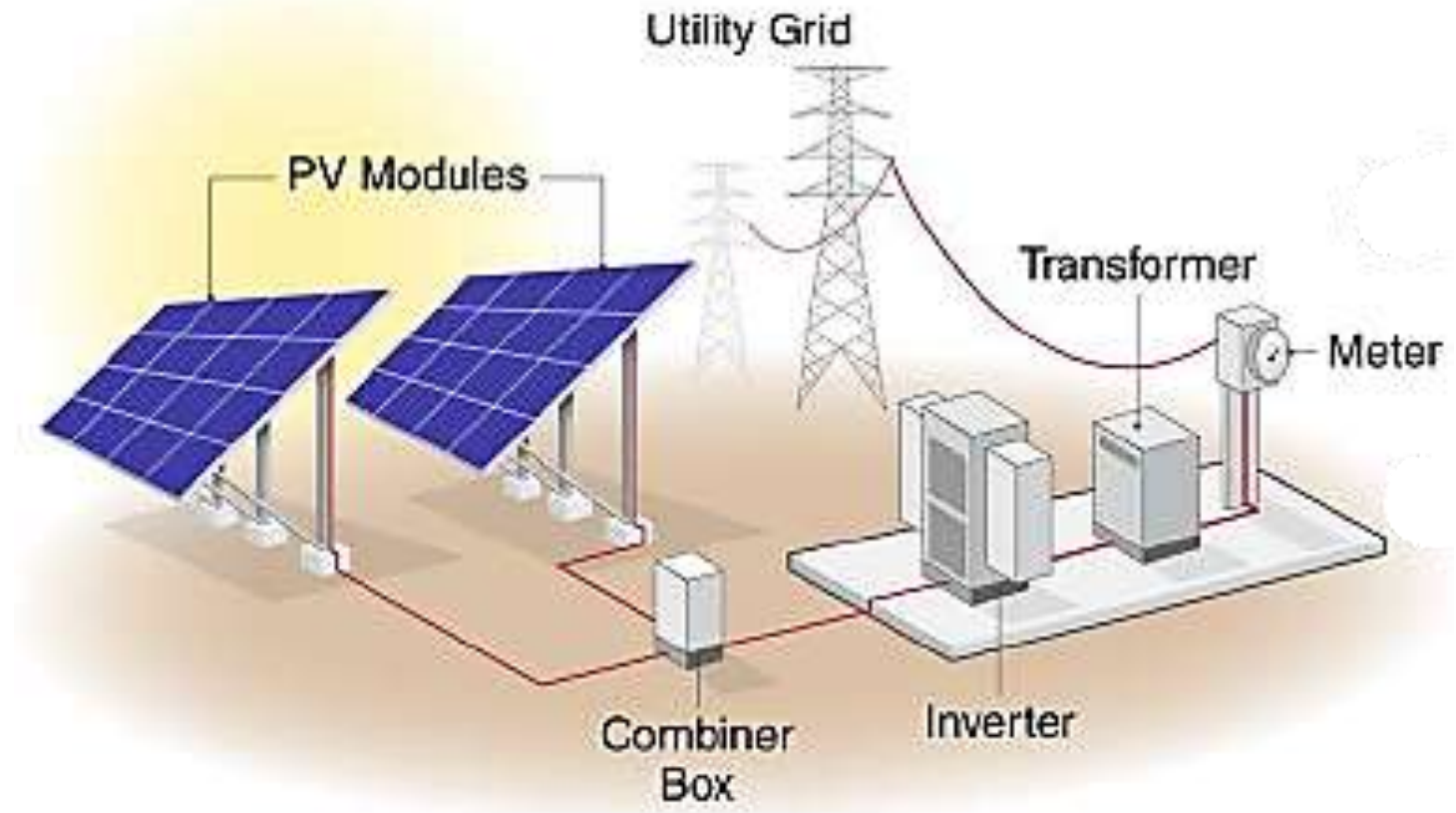


Large Solar PV Arrays: China



Talatan solar project (Qinghai) 16,930 megawatts, 10x Manhattan area → 2030: 100GW PV “Great Wall”.

Utility PV Installation



Residential/Commercial Installations



European installations: Balcony Power, 1.8 kWp. Bifacial cells, battery storage 1.6 kWh incl. 800W inverter.



Solar thermal installation at the Allison Inn, Oregon

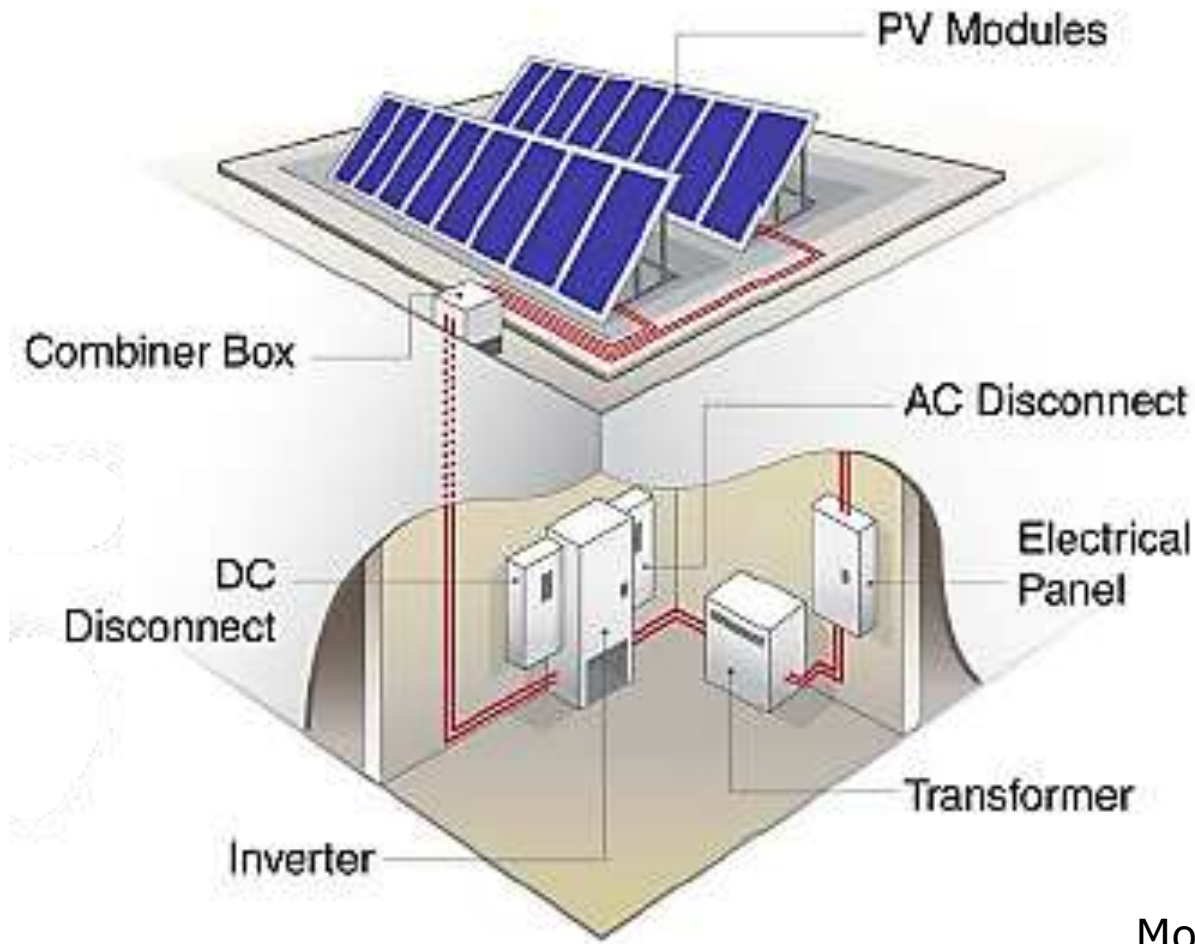
U.S. 2024: 4.7GW_{dc}.

2022 total: 5.9 GW_{dc} = nearly 700,000 systems installed

(1,687 MW_{dc} in Q4)

Supply chain problems: China, tariffs

Residential/Commercial PV Installation



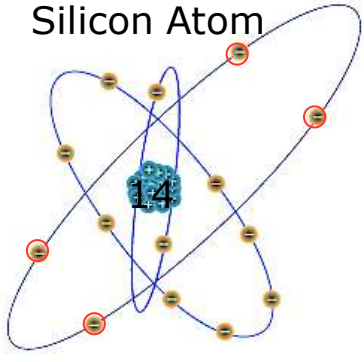
More compact setups for
"Balcony Power Plants"

Agenda

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PV Basics: Properties of Semiconductors

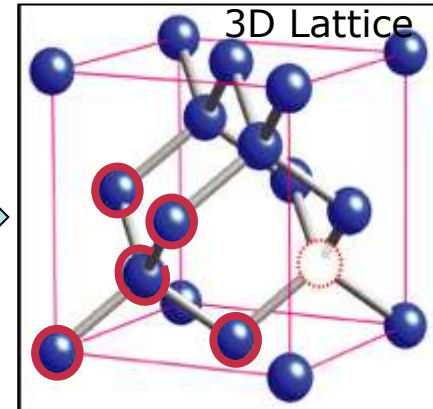
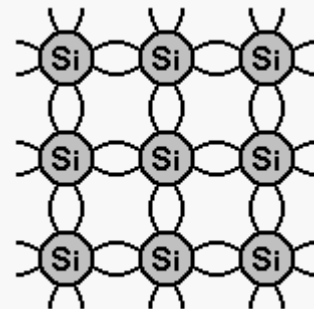
Silicon Atom



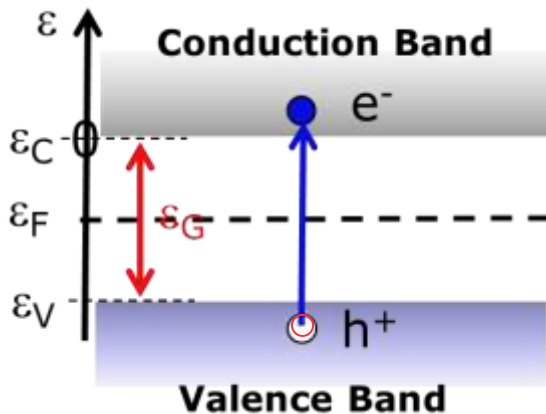
Basic idea of solar cell: Photons electrically polarize non-conductive cell, generate currents of charge carriers → external electric circuits.

Crystal lattice: Covalent binding of 4 valence e^- in "valence" band of states. Free e^- (h^+) in conduction bands.

2D Structure



Band Structure of Electron States in Periodic Crystal Lattices



Magnitude of **band gap ϵ_G** → electrical properties/conductivity.

ϵ_G : Si: 1.11, Ge: 0.66, InSb: 0.17, InAs: 0.36, InP: 1.27, GaP: 2.25 eV.

Energy band structure of all matter lattices
Semi-conductors (have small gaps) →
Thermal Boundary Fluctuations

- Pure elements of Group IV (Si, Ge,...)
- Binary compounds (GeAs, InSb, SiC, CdSe,...)
- oxides
- Organic compounds (COP)

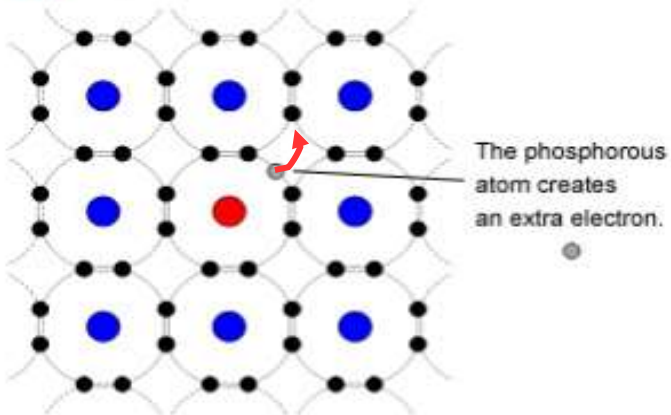
Need spontaneous spatial charge separation →
Not achieved with single homogeneous SC →
join 2 SCs with chemical/electrical pots $\epsilon_{F1} \neq \epsilon_{F2}$
→ **n-silicon & p-silicon**

Diversification: Silicon Doping

Desired: semi-conductor materials with different e^-/h^+ mobilities \rightarrow "doping" Si crystals

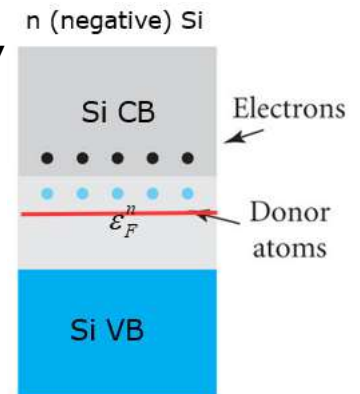
N-Type Silicon

● Phosphorous nucleus



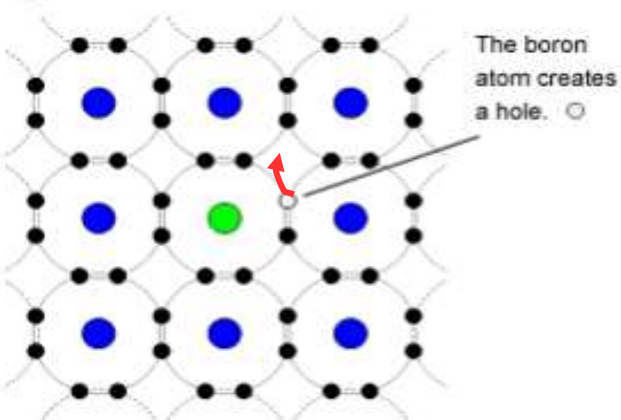
P (phosphorus, Group V element) **one valence electron more** than Si, less bound \rightarrow Si-conduction band.

P-doped Si = **N-type silicon**
P is an electron donor.



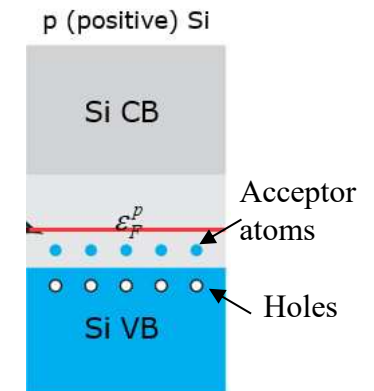
P-Type Silicon

● Boron nucleus

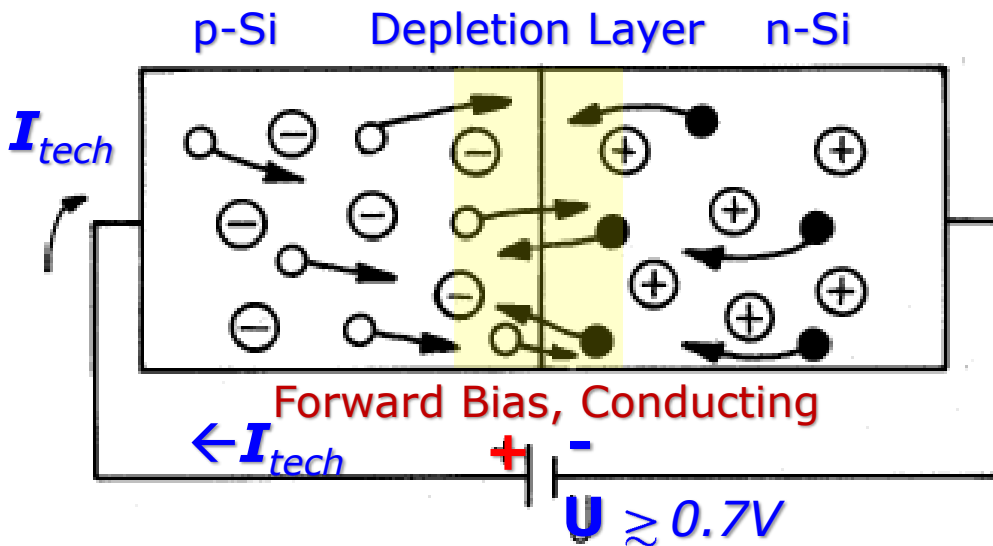


B (boron, Group III element) **one electron less** than Si, extra hole in \rightarrow Si-valence band moves in that band.

B-doped Si = **P-type silicon**,
B is an electron **acceptor**.



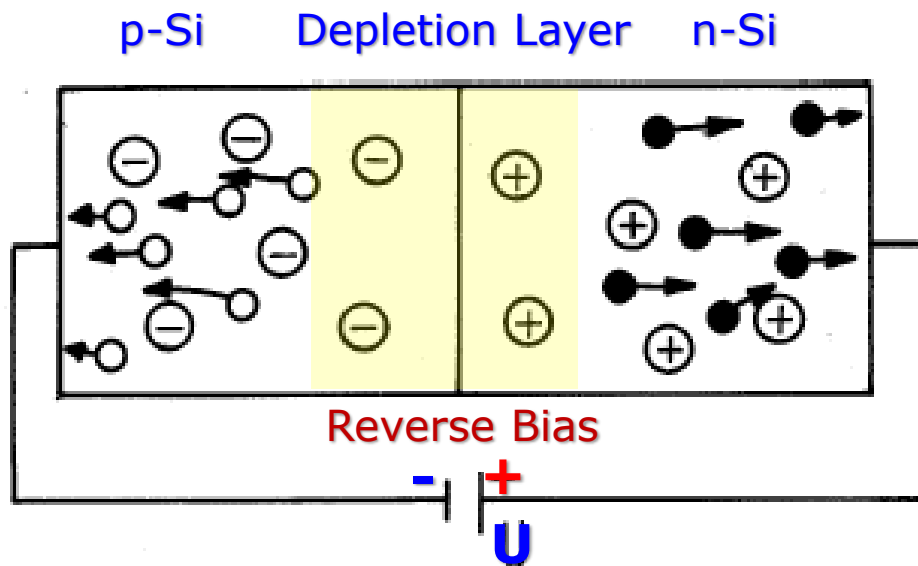
p-n Junction Diode



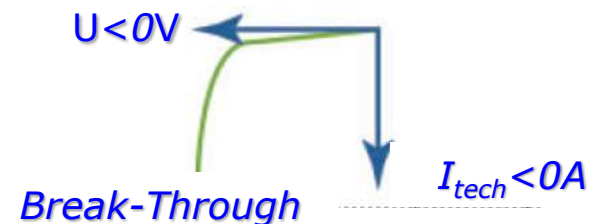
Cross diffusion of e^- and h^+ in junction zone \rightarrow recombination & Potential E **diffusion barrier**
 $B(\text{Si})=0.7\text{eV} \rightarrow$

Depletion Layer (DL):
 has no free charge carriers

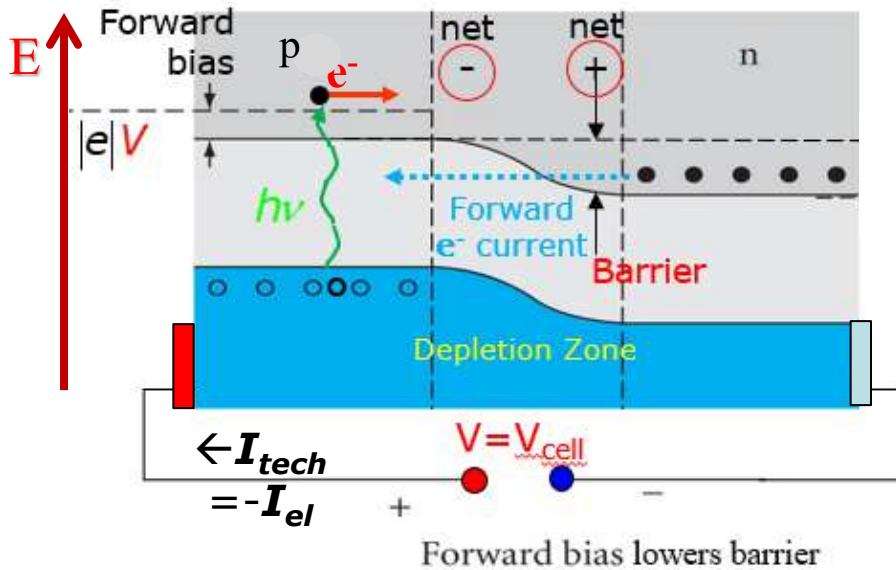
Forward bias $U \gtrsim +0.7V$ (@Si) reduces barrier & width of DL: n-Si electrons move through p-Si part \rightarrow \approx "short circuit"



Reverse bias $U < 0V$ **increases** barrier & width of DL: n-Si electrons are repelled from DL through \rightarrow \approx "open circuit"



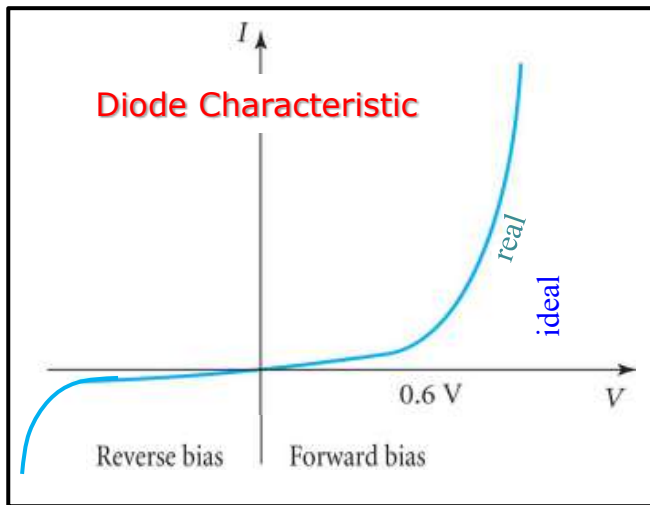
Semiconductor Junction Diodes



Forward: normal $I_{el} = -I_{tech}$: $n \rightarrow p$ across junction due to thermal \rightarrow No Bias applied $\rightarrow I \approx 0$

Forward bias lowers barrier $\rightarrow I \neq 0$, increases. Opto-induced current in opposite direction

Reverse bias: smaller $p \rightarrow n$ reverse e^- current due to thermal transitions over higher barrier. \rightarrow Diode Characteristic



Thermal Dark Current tunneling $\sim \exp\{+e \cdot V/kT\}$
 \rightarrow in normal $n \rightarrow p$ (diode conduction) direction

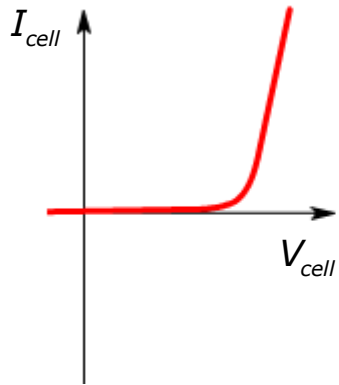
V - induced $I(V) = I_{sat} \cdot \{e^{+e \cdot V/kT} - 1\}$

Ambient T : $kT = 25 \text{ meV}$ @ $T = 293\text{K}$

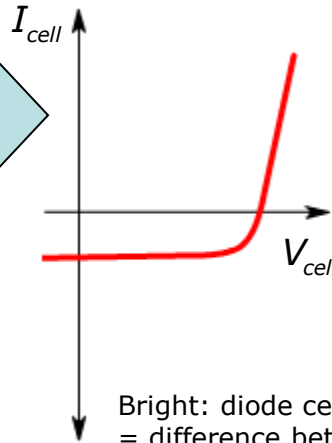
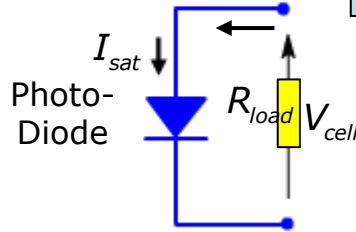
Elementary charge e ,

"Saturation" ("dark", "field") current I_{sat}

Cell Equivalent Electronic Circuits

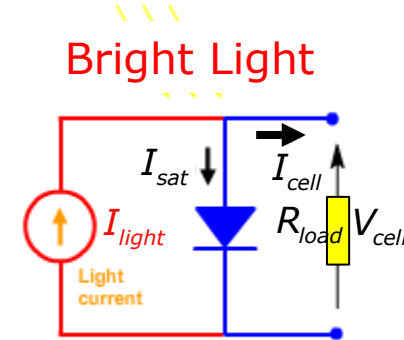


Dark: normal diode functions, saturation dark current

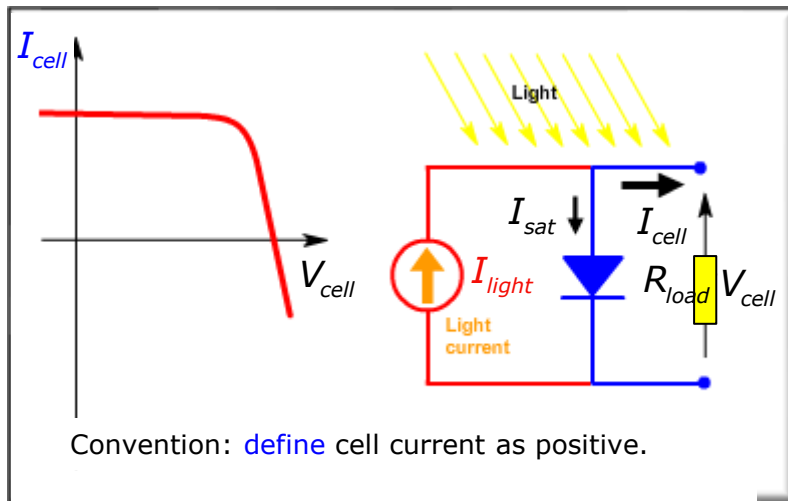


Bright: diode cell current reverses sign, cell current = difference between light and saturation currents

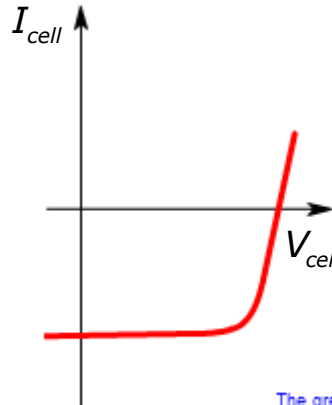
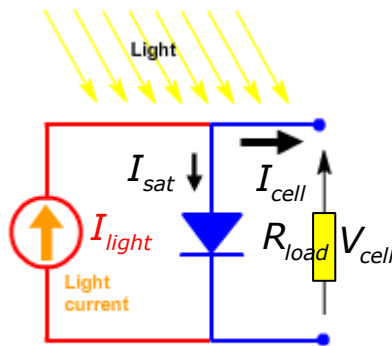
I_{cell} can be measured via R_{Load}



Bright Light



Convention: define cell current as positive.



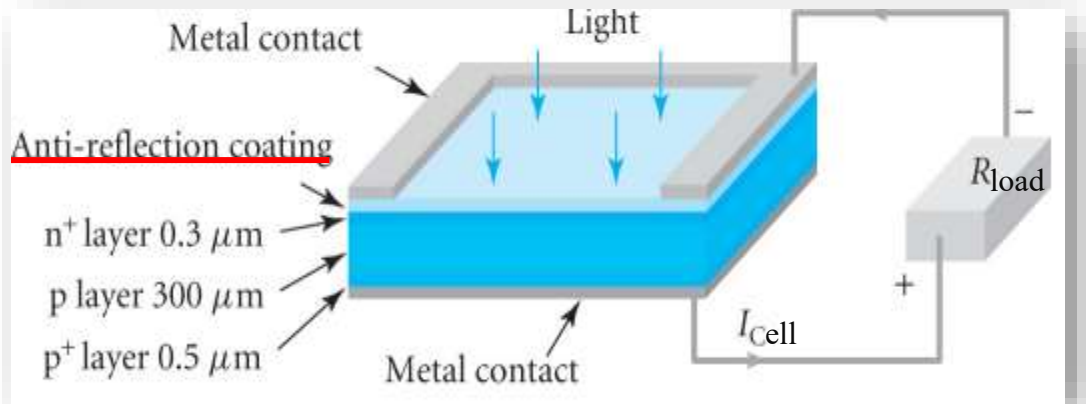
The greater the light intensity

Brighter: diode current becomes more negative, cell current = difference between light and saturation currents increases.

By Convention

Observables in Photocell Operation

Observables: V_{cell} , I_{cell}



+ indicates extra doping, lower resistance.

Light sensitive (solar) cell
Mode of operation

$$\varepsilon_G(Si) = 1.1 \text{ eV}$$

$$\lambda_G = \frac{hc}{\varepsilon_G} = \frac{1.24 \text{ eV}}{\varepsilon_G} \mu\text{m}$$

→ e^- - hole excitation if $\lambda \leq \lambda_G$
dissipates extra e^- kin. energy

I_{cell} dependence on R_{load} →

Photon $h\nu$ produces e^- /hole pair in *depleted* domain →
reverse current of electrons (and holes) $\bar{I}_{Light} \uparrow \downarrow \bar{I}_{sat}$

$$I_{cell} = I_{Light} - I_{sat} \cdot \left\{ e^{e \cdot V_{cell} / kT} - 1 \right\} =$$

$$= I_{Light} - I_{sat} \cdot \left\{ e^{R_{Load} \cdot I_{cell} / V_{th}} - 1 \right\}$$

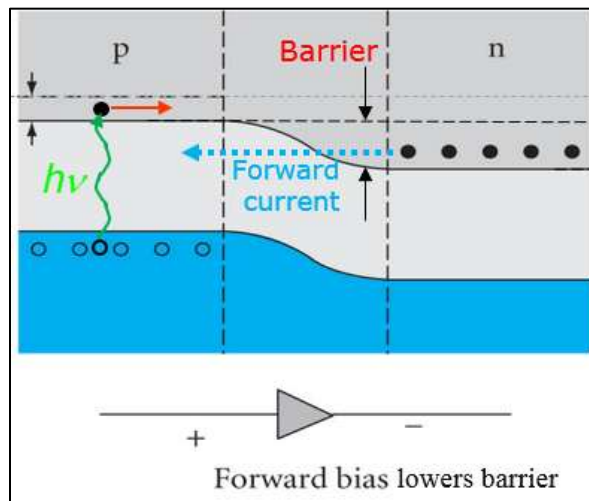
"Thermal voltage"
 $V_{th} := kT/e = 25\text{mV}$
Ohm's Law $V_{cell} = I_{cell} \cdot R_{Load}$

$R_{Load} \rightarrow \infty$ (open circuit): $I_{cell} \rightarrow 0$, $V_{cell} =: V_{OC}$

$$V_{OC} = V_{th} \cdot \text{Ln} \left[1 + \frac{I_{Light}}{I_{sat}} \right] \approx V_{th} \cdot \text{Ln} \left[\frac{I_{Light}}{I_{sat}} \right] \rightarrow \boxed{V_{OC} = (V_{cell})_{max}}$$

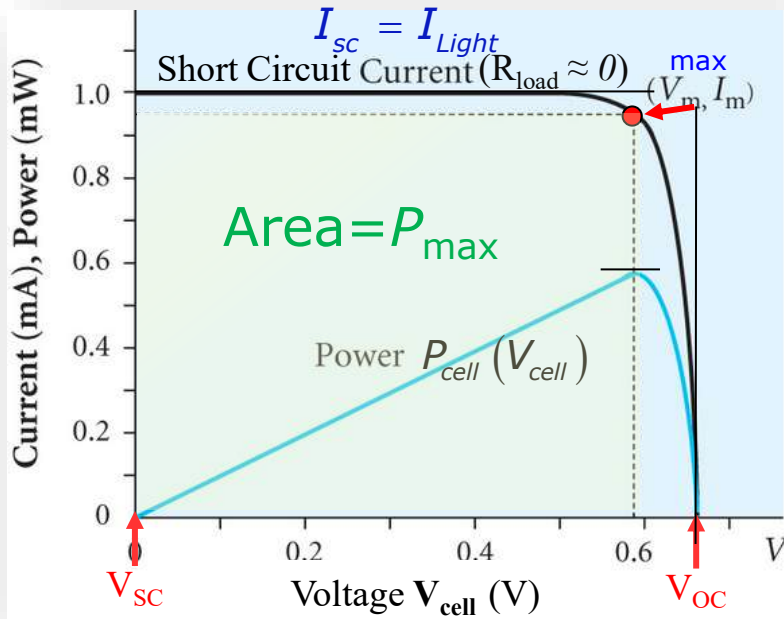
$I_{Light} \gg I_{sat}$

$R_{Load} = 0$ (short circuit): $I_{cell} = I_{sc} = I_{Light}$



Cell Power Characteristic

Cell Current-Voltage Characteristic



Power P_{cell} generated by illuminating cell, scan by varying light intens. or R_{load}

$$(R_{Load} \ll R_{diode}) \rightarrow (R_{Load} > R_{diode})$$

Rise and fall between short-circuit (SC) ($V_{cell} \approx 0$) and open circuit ($I_{cell} \approx 0$).

Between above limits, power evolution :

$$P_{cell} = I_{cell} \cdot V_{cell}$$

$$P_{cell} = I_{cell}^2 \cdot R_{load} \quad (Ohm's Law)$$

Current I_{cell} and power P_{cell} decrease with decreasing light intensity.

Typical nominal values: $I_{cell} = 1\text{mA}$, $I_{sat} = 10^{-12}\text{ A}$, $V_{oc} = 0.66\text{ V}$,

Actual $P_{cell} \leq P_m = 0.58\text{ mW}$, $V_{cell} \leq V_m = 0.58\text{V} \rightarrow \text{const } I_{cell} \leq I_m = I_{sc} = 0.95\text{ mA}$

"Fill Factor": $FF = P_{max} / (I_{sc} \cdot V_{oc})$
 Deduce from $\{I_{sc}, V_{oc}\} \rightarrow P_{max} = FF \cdot I_{sc} \cdot V_{oc}$

FF=Ratio of area under power curve to limiting rectangle \rightarrow measure of steepness (ideal) of diode I-V characteristic.